

# CAPITAL MARKETS DAY 2020 INSIGHTS BONDER

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Stefan Lutter, Business Unit Manager Bonder



# MORE THAN MOORE MARKET AND TECHNOLOGY TRENDS - APPLICATION DRIVERS FOR WAFER BONDING



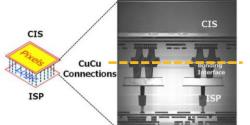
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- → Demand for "More than Moore" devices is expected at CAGR (2017-23) of 4 13% by Yole Développement
- + Wafer to Wafer (W2W) and Die to Wafer (D2W) bonding is required in many of these applications see examples below

### Overall wafer demand for More than Moore devices Breakdown by More than Moore application - in 8 inch eq

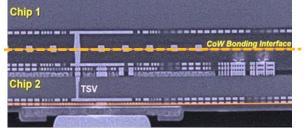


Source: Yole (2018, 2019)



Sony CMOS Image Sensor (CIS) Source: Sony (2019)

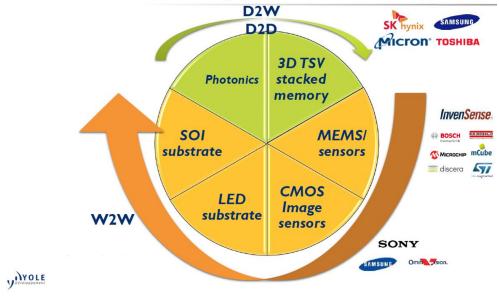
InvenSense 7-axis MEMS Source: SystemPlus (2017)



tsmc SoIC<sup>™</sup> chip with 4μm TSVs and pitch of 9μm Source: Techsearch (2020)

#### APPLICATIONS REQUIRING PERMANENT BONDING

W2W Assembly technology used for More than More applications





# MORE THAN MOORE MARKET AND TECHNOLOGY TRENDS - 2.5D AND 3D STACKING TECHNOLOGY

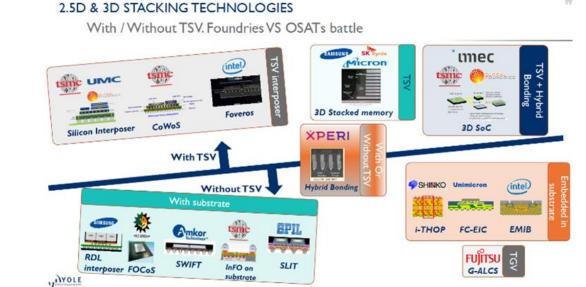


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BSI CIS

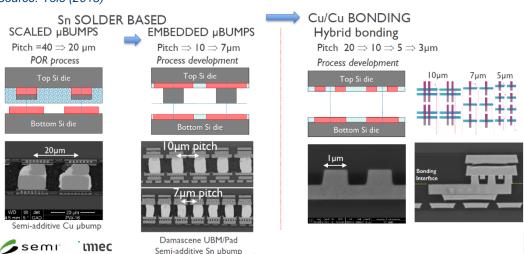
- + 2.5D and 3D requires temporary bonding for wafer thinning as well as D2W or W2W bonding
- D2W bonding enables heterogeneous integration, high yield is achieved by stacking known good dies (KGD)
- Hybrid bonding will be the main enabler for pitch scaling
   (TSV and µbump → Cu/Cu interconnects = hybrid bonding)
  - Used for latest generations of CMOS image sensors since 2017
  - Will be used for other new 3D devices by IDMs and foundries
- Equipment market is forecasted at CAGR (2018-25) of ~25% by Yole Développement

#### **Bonding** Interface(s) ..... ......... ....... . . . . . . . . . . . . No 3D IC No pitch 5µm pitch 2.5µm pitch <2 µm pitch <0.1 µm < 5µm <0.5 µm <0.2 µm <0.12 µm 2016 8GB HBM2 (3D memory) Source: Yole (2018) Source: Samsung



Source: Yole (2018)

Source: imec (2020)



### PRODUCT PORTFOLIO



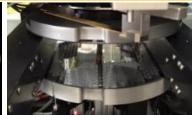
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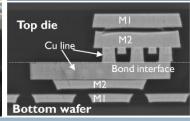
#### **Business Unit Bonder**

#### More than Moore - MEMS and related









#### More than Moore - 2.5D and 3D







**Semi-Automated Bonders** 

**Automated Permanent Bonders** 

#### **Automated Temporary Bonders, Debonders and Cleaners**







XB8 (100kN)



XBS200 W2W Bonder



XBS300 W2W / collective D2W Bonder



XBS300 Temporary Bonder



XBC300 Gen2 Debonder (mechanical / laser) and Cleaner

### Comment / USP

- Large installed base
- Supports all traditional processes
- Supports new high force / high end processes
- Fixture-less aligned wafer handling for best cost of ownership
- <100nm overlay to support pitch scaling trend in hybrid bonding
- Large installed base with ~40-50%<sup>1)</sup> market share for 2.5D and 3D memory
- Technology enabler applications such as CIS, FO-WLP
- Started transition from mechanical- to laser debonding for next generation of devices

# GROWTH POTENTIAL – ON TRACK WITH SUSS STRATEGY 2025 PROJECTION



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